

11/21/03

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	Interconnect Structure Diffusion Barrier with High Nitrogen Content
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Application Number :

Confirmation Number:

First Named Applicant: Cyril Cabral

Attorney Docket Number: FIS920030252US1

Art Unit:

Examiner:

Search string: (6346745 or 6491978 or 6117769 or 20010041250 or 20020030222 or 20030032281),pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
KR	1	6346745	2002-02-12	NOGAMI, ET AL.			
I	2	6491978	2002-12-10	KALYANAM			
KR	3	6117769	2000-09-12	NOGAMI, ET AL.			

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
KR	1	20010041250	2001-11-15	WERKHOVEN, ET AL.			
I	2	20020030222	2002-03-14	AGARWAL			
KR	3	20030032281	2003-02-13	WERKHOVEN, ET AL.			

Signature

<div style="display: flex; align-items: center;"> <div>Examiner Name</div> </div>	<div style="display: flex; align-items: center;"> <div style="width: 40px;"></div> <div>Date</div> </div> <div style="text-align: center; margin-top: 10px;">6/2/05</div>
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